IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):

Jeffrey Lutze et al.

Title:

Self Aligned Non-volatile Memory Cell and Process for Fabrication

Application No.:

10/600,259

Filing Date:

June 20, 2003

Examiner:

Not yet assigned

Group Art Unit:

2818

Docket No.:

SNDK.310US0

Conf. No.:

7482

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Pursuant to 37 C.F.R. §§ 1.56, 1.97 and 1.98, Applicant(s) call(s) the documents listed on the enclosed Form PTO-1449 to the Examiner's attention in this patent application.

Copies of the documents listed on the accompanying Form PTO-1449 are enclosed.

Citation of these documents shall not be construed as (1) an admission that the documents are prior art with respect to the invention or inventions claimed in this application, (2) a representation that a search has been made (other than as indicated by any cited document), or (3) an admission that the cited information is, or is considered to be, material to patentability as defined in § 1.56(b).

This information disclosure statement is submitted under 37 C.F.R. § 1.97(b) and consequently no fee should be required. The Commissioner is authorized, however, to charge any fee that may be required, or to credit any overpayment, against Deposit Account No. 502664. This form is being submitted in duplicate.

EXPRESS MAIL NO.:

EV437667867US

Respectfully submitted,

Gerald P. Parsons

Reg. No. 24,486

Date

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